IN THE UNIT

ATENT AND TRADEMARK OFFICE

rial No.: 10/083,877

icant: Alan Wong et al.

Title

: February 25, 2002

MEASUREMENT ,

: OPTICAL METRO

Art Unit: 2811

Examiner: Unknown

FARGET DESIGN FOR SIMULTANEOUS

LTIPLE PERIODIC STRUCTURES

Commissioner for Patents Washington, D.C. 20231

INFORMATION DISCLOSURE STATEMENT

Applicant submits the references listed on the attached form PTO-1449, copies of which are enclosed.

This statement is being filed before the receipt of a first Office action on the merits.

Please apply any charges or credits to Deposit Account No. 06-1050.

Respectfully submitted,

Scott R. Boalick Reg. No. 42,337

Fish & Richardson P.C. 1425 K Street, N.W. 11th Floor

Washington, DC 20005-3500 Telephone: (202) 783-5070 Facsimile: (202) 783-2331

40105307.doc

itute Form PTO-1449	U.S. Department of Commerce Pat ent and Trademark Office	Attorney's Docket No. 10559-591001	Application No. 10/083,877	
Dormation Disclosure Statement	closure Statement	Applicant Alan Wong et al.		
	eets if necessary)	Filing Date February 25, 2002	Group Art Unit	

U.S. Patent Documents							
Examiner Initial	Desig. ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Trans Yes	lation No
	AB							

	Other D	ocuments (include Author, Title, Date, and Place of Publication)				
Examiner Initial	Desig. ID	Document				
	AC	International Technology Roadmap for Semiconductors 2000 Update, "Metrology", pages 1-12.				
	AD	International Technology Roadmap for Semiconductors 2000 Update, "Overall Roadmap Technology Characteristics", pages 1-32.				
	AE	International Technology Roadmap for Semiconductors 1999 Edition, "Metrology", pages 295-313.				
	AF	International Technology Roadmap for Semiconductors 1999 Edition, "Introduction", pages 1-22.				
	AG	International Technology Roadmap for Semiconductors 1999 Edition, "Overall Roadmap Technology Characteristics and Glossary", pages 1-22.				
	АН	International Technology Roadmap for Semiconductors, "On-Line ITRS Documents", 3 pages: http://public.itrs.net/Reports.htm , last updated June 4, 2001(printed 10/26/2001), http://public.itrs.net/Files/2000UpdateFinal/2kUdFinal.htm , last updated December 15, 2000 (printed 10/26/2001), http://public.itrs.net/Files/1999 SIA Roadmap/Home.htm, (printed 10/26/2001).				
	AI	"EEEL, OMP, Optical-Based Dimensional Metrology", 8 pages, http://www.eeel.nist.gov/omp/dimension_optical.html, dated June 12, 2001 (printed 10/22/2001).				
	AJ	"EEEL, OMP, Critical Dimension and Overlay Metrology Program", 1 page, http://www.eeel.nist.gov/omp/dimension.html , dated June 12, 2001 (printed 10/22/2001).				
	AK	"Nanotechnology", 8 pages, http://www.eeel.nist.gov/812/nano.html, (printed 10/22/2001).				
	AL	"EEEL, OMP, Electrical-Based Dimensional Metrology", 7 pages, http://www.eeel.nist.gov/810.01/dimension_electrical.html , dated June 12, 2002 (printed 10/22/2001).				
	AM	"The Fundamentals of Overlay Metrology", 4 pages, http://www.e-insite.net/semiconductor/index.asp?layout=articlePrint&articleID=CA159008 , dated 9/1/2002 (printed 01/21/2002).				
	AN	International Technology Roadmap for Semiconductors 2001 Edition, "Executive Summary", pages 1-57.				
	AO	International Technology Roadmap for Semiconductors 2001 Edition, "Metrology", pages 1-24.				
	AP	"2001 ITRS Home Page", 2 pages, http://public.itrs.net/Files/2001ITRS/Home.htm, (printed 01/21/2002).				
	AQ	"The Fundamentals of Overlay Metrology – SI September 2001", 6 pages, http://www.google.com/search?q=cache:ofSQhAFmV6UC:209.67.253.149/semiconductor , (printed 01/21/2002).				

Examiner Signature	Date Considered				
	<u> </u>				
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with					
next communication to applicant,					